

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of: )  
 )  
Nozawa et al. )  
 )  
Serial No.: 10/667,823 )  
 )  
Filed: September 22, 2003 )  
 )  
For: Phase Mask Shift Blank, Photo Mask Blank, )  
And Manufacturing Apparatus And Method )  
Of Blanks )  
 )  
Examiner: Rodney Glenn McDonald )  
 )  
Confirmation No.: 1017 )  
 )  
Art Unit: 1753 )

Commissioner of Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT D**

Dear Sir:

In response to the Office Action of July 19, 2006, please amend the above-identified application as follows: